

## Surface-enhanced infrared detection of benzene in air using a porous metal-organic-frameworks film

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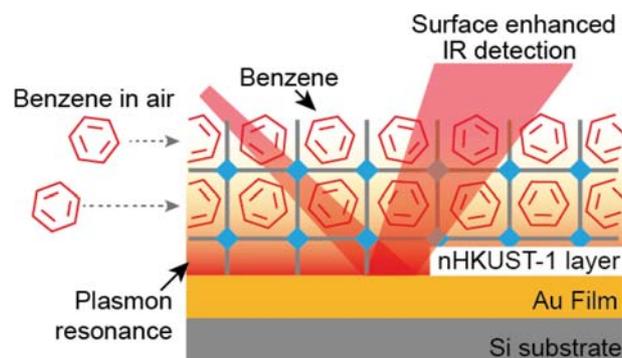
**Abstract**—Infrared (IR) spectroscopy is a powerful technique for observing organic molecules, as it combines sensitive vibrational excitations with a non-destructive probe. However, gaseous volatile compounds in the air are challenging to detect, as they are not easy to immobilize in a sensing device and give enough signal by themselves. In this study, we fabricated a thin nanocrystalline metal-organic framework (nMOF) film on a surface plasmon resonance (SPR) substrate to enhance the IR vibration signal of the gaseous volatile compounds captured within the nMOF pores. Specifically, we synthesized nanocrystalline HKUST-1 (nHKUST-1) particles of *ca.* 80 nm diameter and used a colloidal dispersion of these particles to fabricate nHKUST-1 films by a spin-coating process. After finding that benzene was readily adsorbed onto nHKUST-1, an nHKUST-1 film deposited on a plasmonic Au substrate was successfully applied to the IR detection of gaseous benzene in air using surface-enhanced IR spectroscopy.

**Keywords:** Metal-organic Frameworks, Porous Film, Surface-enhanced IR Spectroscopy, Volatile Organic Compounds, Plasmon Resonance

### INTRODUCTION

Surface-enhanced infrared (IR) absorption spectroscopy (SEIRAS), which exploits the signal enhancement induced by the surface plasmon resonance (SPR) of thin metal films [1-3], has proven to be a powerful method to improve the IR detection limits of molecules whose small absorption cross sections do not provide adequate IR signal. Such enhanced IR absorption has been utilized in various sensor, photonics, and enhanced spectroscopy applications [4-16]. However, these applications are generally limited to molecules immobilized on the plasmonic surface, as the plasmon enhancement decays exponentially with distance. For gaseous organic molecules in air, their surface-enhanced IR detection has been challenging, as they are not easily immobilized on the plasmonic surface and usually co-exist with other gases in air. Especially for the non-polar volatile organic compounds (VOCs) such as benzene, they are necessarily required to be concentrated from the air on either an adsorbent or by trapping whole air in a container, followed by using gas chromatography (GC) [17], Fourier transform infrared spectrometer (FT-IR) [18], proton transfer reaction mass spectrometer (PTR-MS) [19], and membrane interface mass spectrometry [20]. Therefore, these processes all need large amount of air and long process time for measuring benzene in air.

A metal-organic framework (MOF) is known as a functional microporous material capable of capturing target molecules exist-



**Fig. 1.** Schematic diagram for surface-enhanced IR detection of benzene in air using an nHKUST-1 layer fabricated on the Au substrate.

ing in air. We envisioned that a thin layer of an MOFs coated on a plasmonic metal film can capture target gases sufficiently near the plasmonic surface to enhance their IR signal (Fig. 1). In this report, we prepared colloidal solutions of nanocrystalline MOFs (nMOFs) and fabricated an nMOF layer on a SPR film to test the surface-enhanced IR detection of benzene. Specifically, we chose HKUST-1 as an exemplar case of MOF, as it is known to have high sorption capability of benzene even in low partial pressure region [21-25]. The HKUST-1 was synthesized in nanocrystalline form (*ca.* 80 nm, referred to as nHKUST-1) with a homogeneous particle size and morphological distribution at room temperature. The nHKUST-1 particles were dispersed in hexane containing oleic acid as a surface modulator to give a colloidal solution, which was then used in a spin-coating process to fabricate an nHKUST-1 layer on an Au

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thin film [26]. After confirming that the nHKUST-1 particles showed high sorption of benzene, the nHKUST-1 film coated on the Au substrate was successfully used to provide the clear vibrational intensity of benzene in air while other films without having either the nHKUST-1 film and the Au substrate were not. This is the report regarding the fabrication of an nMOF layer on a plasmonic substrate by spin-coating process to achieve the surface-enhanced IR detection of benzene in air.

The synthesis of nMOFs was combined with plasmon enhancement in various application fields, including surface-enhanced Raman scattering (SERS) [27-29], SEIRA [30,31], and photosynthesis [10, 32,33] (Table S1). Recently, plasmon enhanced MOF films for on-chip gas sensing have been reported [4], but surface-enhanced IR detection using a nanocrystalline MOF film is still challenging. Previous studies using other materials for the detection of gaseous molecules using spectroscopy have mainly focused on using ultraviolet-visible region [11-14,16,34-37] (Table S2), and the enhanced IR detection still remains challenging. In an attempt to overcome these challenges, we developed an nMOF-based spin-coating process to produce a porous film on SPR substrate and then achieved the surface-enhanced IR detection of gaseous organic compounds.

## MATERIAL AND METHODS

### 1. Chemicals

All reagents were obtained from commercial sources unless otherwise stated and used without further purification. 1,3,5-Benzenetricarboxylic acid ( $H_3BTC$ , 95%), trimethylamine ( $\geq 99\%$ ),  $N,N$ -dimethylformamide (DMF,  $\geq 99\%$ ), and copper(II) acetate monohydrate ( $Cu(OAc)_2 \cdot H_2O$ ,  $\geq 98\%$ ) were purchased from Sigma-Aldrich. Ethanol, acetone, and distilled water were purchased from Dksan. Hexane (95%) was purchased from Samchun. Hypophosphorous acid (50 wt% solution in water) was purchased from Acros.

### 2. Synthesis of nHKUST-1

nHKUST-1 was synthesized using a previously reported process with slight modifications [24]. First, 215 mg of  $Cu(OAc)_2 \cdot H_2O$  was dissolved in 5 mL of DMF in a 20 mL vial, and 126 mg of  $H_3BTC$  and 0.25 mL of triethylamine were dissolved in 2 mL of DMF in a separate vial. These two solutions were then combined into a single solution in a mixture of DMF (18 mL), ethanol (25 mL), and water (25 mL) in a round flask. The mixture was vigorously stirred with a magnetic stir bar for 1 h at room temperature. The resulting nHKUST-1 was washed twice with DMF using a centrifuge (7,000 rpm for 10 min) and sonication. The nHKUST-1 was then sequentially immersed in acetone for a 24 h period three times. Finally, the nHKUST-1 was activated by removing the solvent under vacuum for about 5 h. The final product was obtained as a blue powder.

### 3. nHKUST-1 Film Fabrication Process

70 mg of nHKUST-1 was introduced into a hexane solution containing 53  $\mu$ L of oleic acid and dispersed using sonication for 3 h. In the meantime, the substrates were soaked in hypophosphorous acid (50 wt% solution in water) and sonicated for 1 h to clean their surfaces, and then washed with ethanol, acetone, and water for 1 h each. The substrates were dried using a  $N_2$  stream, and then the nHKUST-1 colloidal solution was deposited and spin-coated

on the substrates (7,000 rpm, 2 min). The oleic acid remaining in the nHKUST-1 film was washed out by soaking the coated substrates in acetone followed by drying with a  $N_2$  stream.

### 4. Surface-enhanced IR Detection

The Si substrate was placed on the top of a thermal evaporator (thermal evaporator system KVT-D665) and then Au source was deposited on the Si substrate for 5 min to produce an Au/Si substrate in a thickness of  $\sim 250$  nm (Fig. S1). The planar SEM image for the Au/Si substrate revealed that the Au layer is composed of nanoparticles ( $\sim 50$  nm in diameter) and have rugged surface (Fig. S1). This surface morphology is advantageous to make the nHKUST-1 particles deposited well on its surface during the spin-coating process, as well as making the plasmonic effect strong for the surface-enhanced IR detection of benzene [38,39]. An nHKUST-1 film was deposited on the surface (nHKUST-1/Au/Si) using the same procedure described above using 2.4 wt% nHKUST-1 colloidal dispersion. For the sorption of benzene within the pores of nHKUST-1 film, the nHKUST-1/Au/Si sample was placed in a sealed chamber containing 1 ml of benzene inside for an hour in room temperature, which makes 12.67 vol% of benzene in air. The excess benzene existing outside of pores in nHKUST-1 was removed by drying the sample in ambient condition. The nHKUST-1/Au/Si sample having benzene molecules inside of its pore was then transferred into an FT-IR spectrometer (Nicolet IS50) for ATR diamond mode measurement. The IR scan range was 1,000-1,200  $cm^{-1}$  with 32 scans for 2 min. Controlled samples of the nHKUST-1 particles (nHKUST-1), an nHKUST-1 film on a Si substrate (nHKUST-1/Si), and an nHKUST-1 film on an Au-coated Si substrate (nHKUST-1/Au/Si) were all tested in the same procedure.

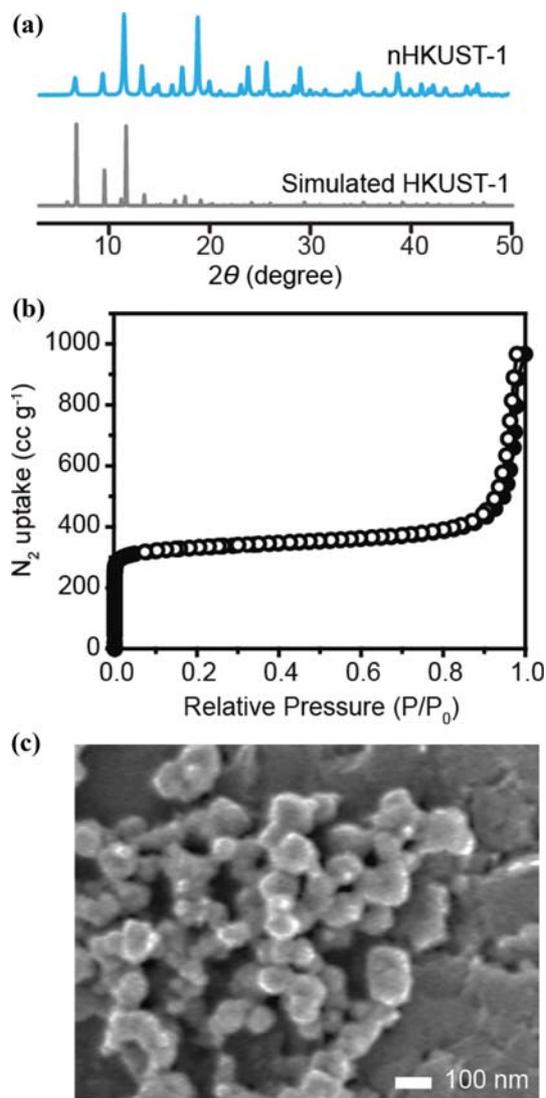
### 5. Characterization

The powder X-ray diffraction (PXRD) spectra were obtained using a Rigaku X-ray diffractometer (Smartlab,  $Cu K\alpha$  radiation) at 1,200 W (40 kV, 30 mA) at a scan rate of  $4^\circ/min$  from  $3^\circ$  to  $50^\circ$  on a silicon holder. Field emission scanning electron microscopy (FE-SEM) was carried out at 3 kV using a JEOL JSM-7600F microscope. For SEM observation, the nHKUST-1 particles were dispersed in acetone and placed on a silicon substrate. Pt was coated onto the samples before they were placed in the SEM chamber. The SEM observations were carried out in GB\_LOW mode, with a WD of 8.0 mm. The nHKUST-1 film was observed in the same way. Solvent and gas adsorption analysis was performed using a BELSORP-max automatic and volumetric adsorption analyzer. Before the gas and solvent sorption measurements, the samples were activated at  $150^\circ C$  for 24 h followed by a purge with nitrogen.

## RESULTS AND DISCUSSION

### 1. Synthesis and Characterization of nHKUST-1 Particles

Nanocrystalline HKUST-1 particles were synthesized by inducing massive nucleation at room temperature. A burst of nHKUST-1 nucleation was triggered by adding triethylamine to a solution of  $Cu(OAc)_2 \cdot H_2O$  and 1,3,5-benzenetricarboxylic acid in a 1:1:1 mixture of DMF/EtOH/ $H_2O$  at room temperature, which resulted in the formation of nanocrystalline particles at room temperature. After 1 h of reaction, the resulting particles were washed with DMF to remove unreacted chemicals and then with acetone to exchange



**Fig. 2.** (a) X-ray diffraction pattern of nHKUST-1 and the simulated pattern of HKUST-1. (b)  $N_2$  adsorption isotherms for nHKUST-1 at 77 K with adsorption and desorption points represented by solid and open circles, respectively. (c) SEM image of nHKUST-1.

the DMF, followed by drying in a vacuum oven.

The crystallinity of nHKUST-1 was confirmed by PXRD analysis (Fig. 2(a)). The experimental diffraction patterns of nHKUST-1 matched the diffraction patterns simulated for HKUST-1, indicating that the crystal structure of nHKUST-1 was identical to that of the single crystals of HKUST-1 [40]. Infrared (IR) and Raman spectroscopy also indicated the chemical natures are identical, even in nanocrystalline form (Fig. S2 and S3) [22,41]. The permanent porosity of nHKUST-1 was also confirmed by the measurement of its nitrogen adsorption isotherm, which showed type-I sorption behavior expected for this MOF (Fig. 2(b)). The Langmuir surface area of the nanocrystalline HKUST-1 was  $1,370 \text{ m}^2/\text{g}$ , which was within the range of bulk HKUST-1 ( $917.6\text{--}2,175 \text{ m}^2/\text{g}$ ) [42]. A representative scanning electron microscopy (SEM) (Fig. 2(c)) and transmission electron microscopy (TEM) (Fig. S4) images of nHKUST-1

shows that the nHKUST-1 particles were approximately *ca.* 80 nm in diameter, uniform in size, and demonstrated identical spherical geometry.

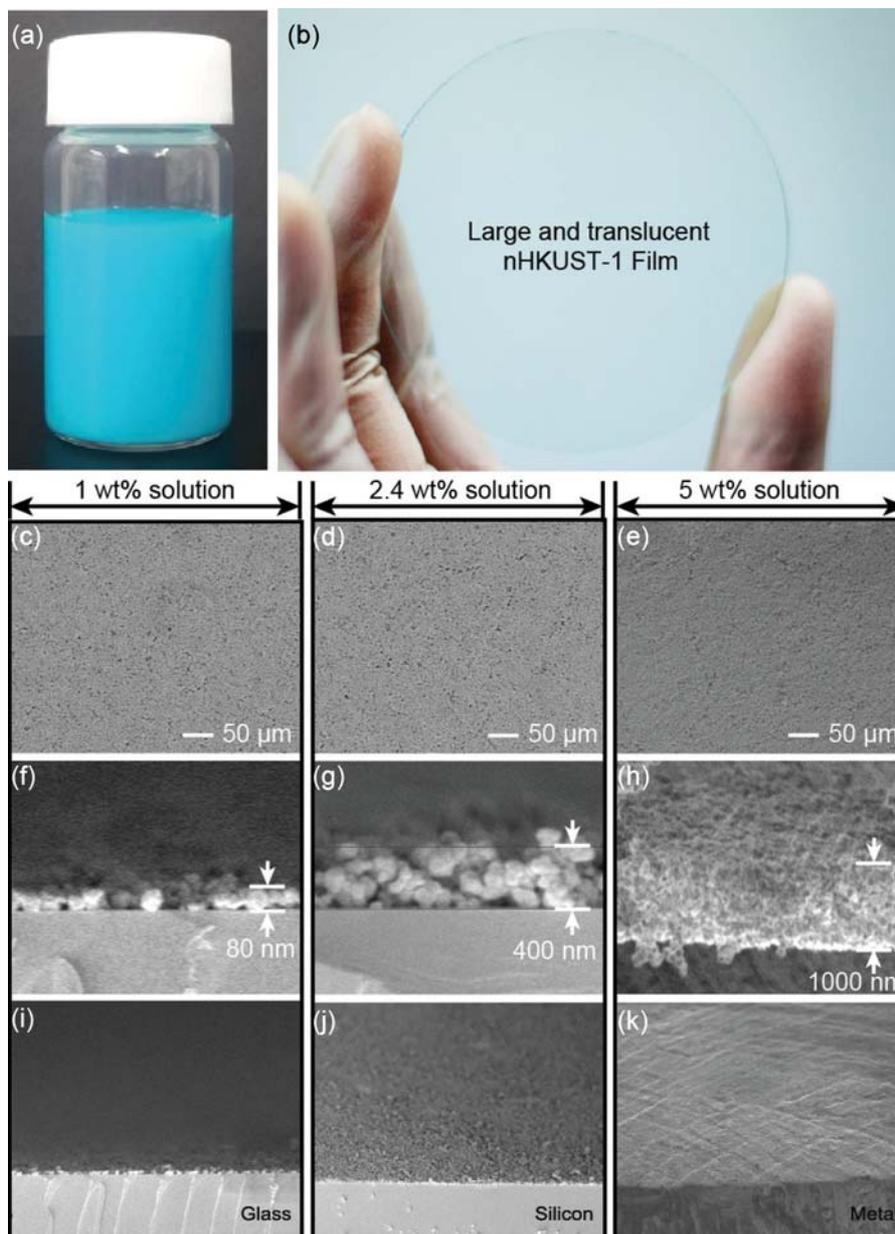
## 2. Dispersion of nHKUST-1 Particles

As we intended to use a spin-coating process for fast and controllable formation of the nHKUST-1 film, the nHKUST-1 particles had to be dispersed in a volatile solvent. However, the surface of nHKUST-1 has many dangling bonds and incompletely bonded metal oxide, which makes nHKUST-1 particles hydrophilic. Our strategy to produce a well dispersed colloidal solution was to use oleic acid as a surfactant, and then disperse the oleic acid coated nHKUST-1 in a non-polar solvent. Oleic acid has a terminal carboxylic group that bonds with the surface of nHKUST-1, and hydrocarbon chains that interact strongly with non-polar solvents such as hexane. The addition of nHKUST-1 particles directly to hexane would result in the formation of large aggregates because the hydrophilic surface of nHKUST-1 interacts unfavorably with the non-polar solvent hexane. However, when nHKUST-1 was added to a mixture of hexane and oleic acid and subjected to sonication for 3 h, a colloidal dispersion of nHKUST-1 was successfully formed (Fig. 3(a)). The colloidal solution maintained its dispersion and was used for the thin-film fabrication the next step.

## 3. Fabrication and Control of nHKUST-1 Film

The formation of nHKUST-1 films was tested on glass substrates that had been pretreated with hypophosphorous acid (50 wt% solution in water) for 1 h followed by washing with acetone, ethanol, and water. Fully dispersed colloidal solutions containing 1.0 wt%, 2.4 wt%, or 5 wt% of nHKUST-1 in hexane were spread onto the cleaned substrates and assembled into thin films by spin-coating (7,000 rpm, 2 min). The surface morphology and thickness of the nHKUST-1 films were observed using SEM and atomic force microscopy (AFM), and the crystallinity of the films was examined by PXRD analysis. As shown in Fig. 3(b), translucent blue nHKUST-1 thin films were successfully fabricated on a large-area transparent substrate.

The films were uniformly deposited over the entire surface of the substrate for all the tested concentrations of nHKUST-1, as shown in the planar SEM images in Fig. 3(c)–(e) and the AFM image in Fig. S5. The thickness of the films depended on the concentration of the colloidal solution; concentrations of 1.0 wt%, 2.4 wt%, and 5 wt% formed 80-nm, 400-nm, and 1,000-nm thick nHKUST-1 films, respectively (Fig. 3(f)–(h)). Note that the 80-nm-thick film consisted of a single layer of nHKUST-1 particles, as shown in Fig. 3(f). As SPR decays exponentially with the distance to the substrate, a single layer of nHKUST-1 was considered to be most suitable to achieve surface-enhanced IR detection. The crystallinity of each of the nHKUST-1 films was evident from their PXRD diffraction lines (Fig. S6), and the preservation of the crystal structure was demonstrated by the coincidence of the diffraction lines for the films with those of the nHKUST-1 particles. We also tested the formation of nHKUST-1 films on glass, silicon and Ti-metal substrates (Fig. 3(i)–(k)). A thin film was successfully formed on all of the tested substrates, and all of the films showed a similar thickness of *ca.* 100 nm. This confirmed that our spin coating process could be applied to plasmonic substrates to achieve specific functions and interactions with guest molecules trapped in the porous MOF films.



**Fig. 3.** (a) Photograph of the nHKUST-1 colloidal dispersion. (b) Translucent blue nHKUST-1 thin film on a large-area transparent substrate. (c)-(e) Planar and (f)-(h) cross-sectional SEM images of the nHKUST-1 films fabricated using nHKUST-1 colloidal solutions with different concentrations of (c), (f) 1 wt% solution; (d), (g) 2.4 wt% solution; (e), (h) 5 wt% solution. (i)-(k) nHKUST-1 films deposited on different substrates.

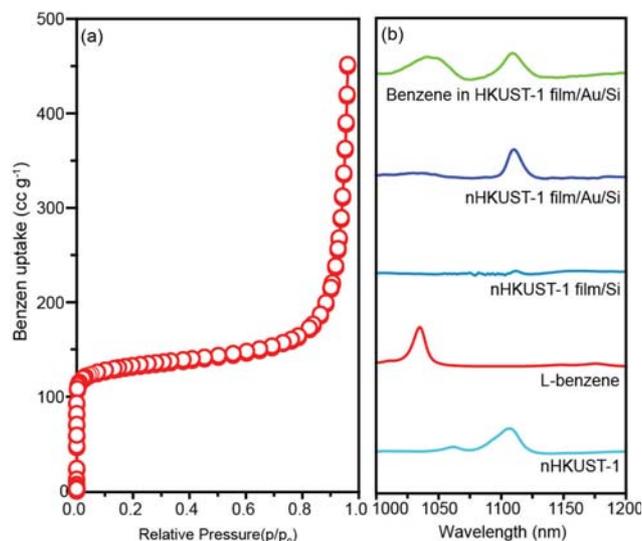
#### 4. Benzene Sorption in nHKUST-1

The surface-enhanced IR performance of the nHKUST-1 film for the detection of molecules in the air was tested using benzene as the target molecule. The sorption capacity of nHKUST-1 for benzene at room temperature was first tested to determine whether the nHKUST-1 particles could trap benzene molecules inside. The sorption capacity was measured by evaporating liquid benzene at room temperature using a Belsorp-Max, and the results are presented in Fig. 4(a). The benzene sorption isotherm showed a type-I sorption behavior, indicating that benzene is rapidly adsorbed in the very low-pressure region and get saturated when relative pressure reaches about 0.08. This data was in good agreement with a

previous report [21,22,40]. It is believed that the micropores of nHKUST-1, which are composed of a number of benzene rings, have a hydrophobic character and thus enhance the sorption capacity towards hydrophobic benzene in the low-pressure region. Considering the low sorption capability of nitrogen, carbon dioxide, and toluene in room temperature (Fig. S7), benzene is favorable to be captured within nHKUST-1 film, where their proximity to the SPR-active plasmonic substrate should result in the enhanced IR detection of benzene.

#### 5. Surface-enhanced Infrared Detection of Benzene in Air Using an nHKUST-1 Film

To evaluate the SPR-enhanced detection of benzene on various



**Fig. 4.** (a) The sorption isotherm of benzene in nHKUST-1 at room temperature. (b) FT-IR spectra for nHKUST-1 particles (nHKUST-1), liquid benzene (L-benzene), an nHKUST-1 film on a Si substrate (nHKUST-1/Si), an nHKUST-1 film on a Au-coated Si substrate (nHKUST-1/Au/Si), and an nHKUST-1 film with adsorbed benzene on a Au-coated Si substrate (Benzene/nHKUST-1/Au/Si).

nHKUST-1 coated substrates, the attenuated total reflectance (ATR) FT-IR spectra of the nHKUST-1 particles (nHKUST-1), liquid benzene (L-benzene), an nHKUST-1 film on a Si substrate (nHKUST-1/Si), an nHKUST-1 film on Au-coated Si substrate (nHKUST-1/Au/Si), and an nHKUST-1 film with adsorbed benzene on Au-coated Si substrate (benzene/nHKUST-1/Au/Si) samples were measured using a Nicolet IS50 from Thermo Scientific ATR-FT-IR Spectrometer (Fig. 4(b)). To prepare the benzene/nHKUST-1/Au/Si sample, benzene was adsorbed onto the nHKUST-1 film through the evaporation of L-benzene in a sealed chamber at room temperature. The characteristic vibrations of the nHKUST-1 and L-benzene samples were observed at 1,120 and 1,043  $\text{cm}^{-1}$ , respectively, which agreed with previous reports [5,22]. For the nHKUST-1 film fabricated on a Si substrate, the signal at 1,120  $\text{cm}^{-1}$  was present, but was difficult to distinguish from the background. For the nHKUST-1 film on the Au substrate, the signal corresponding to nHKUST-1 was enhanced more than three-fold compared with that observed for the Si substrate. This was attributed to the surface-enhanced IR absorption of the nHKUST-1 film as a result of being sufficiently close to the SPR produced by the Au substrate. The IR spectrum of the benzene/nHKUST-1/Au/Si sample shows strongly enhanced vibration signals at 1,120 and 1,043  $\text{cm}^{-1}$  for nHKUST-1 and benzene, respectively. The sensitivity for benzene is about  $6.3 \times 10^{-3}$  area/vol% at vibration signal of 1,043  $\text{cm}^{-1}$ . It is noteworthy that the samples without either nHKUST-1 or Au layer on Si substrate did not show any vibrational signal for benzene, even when extended exposure and measurement times were used. These results indicate that our method of fabricating a porous thin film of a MOF on a plasmonic substrate provides a facile way to observe gas molecules using surface-enhanced IR detection, and provides the possibility to further investigate their gas-state reac-

tion mechanisms using enhanced *in-situ* IR signals.

## CONCLUSIONS

We have demonstrated a fast and controllable way to achieve surface-enhanced IR detection of benzene by fabricating porous nHKUST-1 films on a plasmonic substrate using a spin coating process. We synthesized homogeneously distributed nHKUST-1 particles with a diameter of *ca.* 80 nm and dispersed them in a volatile solvent to form a colloidal dispersion. The solution was deposited on various substrates, and thin films were formed using a spin coating process. The nHKUST-1 films were then coated onto Au-coated substrates capable of producing SPR. The vibration signals of the benzene captured within the pores of the nHKUST-1 film were greatly enhanced by the plasmon resonance, allowing the detection of benzene in air. The fast and controllable formation of the microporous MOF film on the plasmonic substrate provides a synergistic combination for the surface-enhanced IR detection of volatile organic compounds.

## ACKNOWLEDGEMENTS

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## SUPPORTING INFORMATION

Additional information as noted in the text. This information is available via the Internet at <http://www.springer.com/chemistry/journal/11814>.

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